Hafnium Oxide Sputtering Target, HfO2

Fill in this PDF, save a copy, and attach it with your drawing to your inquiry.

01 MATERIAL REQUIREMENTS

Confirm HfO2 identity and any required oxygen stoichiometry

Undoped or specified dopant; state concentration and basis

Required impurity limits and any phase or density criteria

02 GEOMETRY AND ORDER

Drawing number / revision and finished dimensions with units

Cathode model, backing / bonding request and fit tolerances

Quantity, requested delivery date and project reference

03 DOCUMENTS AND ACCEPTANCE

Requested documents: batch CoA, dimensional report, SDS or other

Acceptance criteria, test methods and additional requirements

Enter your required values. Feasibility, final specifications and acceptance criteria are confirmed in the quotation. This worksheet contains no measured batch results.

Send your completed worksheet: sales@thinfilmmaterials.com

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